Structure and Orientation Determination of Metal-Oxide Nanostructures by Electron Backscatter Diffraction

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Crystal growth directions, epitaxial relationships, and identities of crystallographic surfaces are all fundamental parameters that will influence novel electronic, chemical, mechanical or optical behavior in nanostructures. Electron backscatter diffraction (EBSD) stands as a robust approach for rapidly determining the crystal structure and orientation of nanostructures. However, aside from a few recent studies, including analysis of GaAs [1] and GaN [2] nanowires, EBSD has not been widely applied towards studying nanostructures.

In this study, EBSD is utilized to investigate the structure and orientation of metal-oxide nanostructures. Nanowires (NWs) and nanoribbons are grown on various substrates via the vapor-deposition approach. Kikuchi patterns are recorded using a commercial EBSD system housed inside a scanning electron microscope operating at 10 or 20 keV.

Vertical Sn-O NWs grown on c-plane Al₂O₃ substrates with Au catalyst, shown in Fig. 1, exhibit the rutile SnO₂ structure as determined by EBSD. The vertical nature of these SnO₂ NWs allows direct comparisons to the known substrate surface plane. The analysis consistently shows that these NWs grow along the [100] direction and exhibit an epitaxial relationship where the SnO₂ (100) plane is parallel to the Al₂O₃ (0001) plane, and the SnO₂ [010] and [001] directions are parallel to the Al₂O₃ [1210] and [1010] directions, respectively [3]. This EBSD approach is also employed to determine the growth direction and exposed surfaces of SnO₂ nanoribbons.

EBSD can also be extremely complimentary to other techniques, such as cathodoluminescence (CL) spectroscopy. A CL-based real-color imaging technique developed to monitor the luminescence characteristics of nanostructures has been applied to image unique Ga-Sn oxide heterostructures, shown in Fig. 2. Optical properties are inhomogeneous along the heterostructure length ranging from intense blue emission, peak-centered at 430 nm, to broad red emission at 600 nm. According to electron dispersive spectroscopy (EDS), these heterostructures show a conversion in cation composition from Ga-dominant to Sn-rich, with O nearly evenly distributed throughout. Changes in optical and chemical properties directly correlate with the results of spot EBSD analysis. The Ga-rich, blue emission phase is monocrystalline β-Ga₂O₃, while the red luminescent regions are identified as polycrystalline rutile SnO₂.

The observation of orientation variation along these nanostructure lengths, as well as optimal SEM voltage and current parameters for EBSD analysis of different nanostructure diameters is discussed.

References

Fig. 1. Vertical SnO$_2$ nanowires grown on c-plane Al$_2$O$_3$ substrates imaged by (a) SEM. EBSD analysis confirms the nanowires are (b-c) rutile SnO$_2$ and also indicates an epitaxial relationship to the (d-e) corundum Al$_2$O$_3$ substrate. This epitaxial relationship (f) can be summarized as SnO$_2$ (100) || Al$_2$O$_3$ (0001) with SnO$_2$ [001],[010] || Al$_2$O$_3$ [1010],[1210].

Fig. 2. A Ga-Sn oxide nanostructure imaged by (a) SEM and (b) cathodoluminescence. The blue luminescent portion of the nanoscale heterostructure is Ga rich according to EDS and exhibits (c) the monoclinic $\beta$-Ga$_2$O$_3$ crystal structure according to spot EBSD analysis. The opposite end of the heterostructure is red luminescent, Sn rich according to EDS analysis, and exhibits (d) the rutile SnO$_2$ crystal structure according to spot EBSD analysis.